	Application No.	Applicant(s)
Notice of Allowability	09/899,937	SHIMAZAWA ET AL.
	Examiner	Art Unit
	Christopher R. Magee	2653
The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS (herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGOR OF THE NOTICE	OR REMAINS) CLOSED in this ago or other appropriate communication GHTS. This application is subject	oplication. If not included n will be mailed in due course. THIS
1. This communication is responsive to amendment after final,	, filed 11/22/05.	
2. The allowed claim(s) is/are 1-14.		
 Acknowledgment is made of a claim for foreign priority under a)	been received. been received in Application No	
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of noted below. Failure to timely comply will result in ABANDONMI THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	of this communication to file a reply ENT of this application.	complying with the requirements
 A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which give: 	tted. Note the attached EXAMINEF s reason(s) why the oath or declar	R'S AMENDMENT or NOTICE OF ation is deficient.
 CORRECTED DRAWINGS (as "replacement sheets") must (a) including changes required by the Notice of Draftsperson (b) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date 	on's Patent Drawing Review (PTC	
Identifying indicia such as the application number (see 37 CFR 1.6 each sheet. Replacement sheet(s) should be labeled as such in the	84(c)) should be written on the draw e header according to 37 CFR 1.121	ings in the front (not the back) of (d).
DEPOSIT OF and/or INFORMATION about the depose attached Examiner's comment regarding REQUIREMENT F	it of BIOLOGICAL MATERIAL	must be submitted. Note the
Attachment(s)		
1. Notice of References Cited (PTO-892)	5. Notice of Informal I	Patent Application (PTO-152)
 Notice of Draftperson's Patent Drawing Review (PTO-948) ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/08 	6. ☐ Interview Summary Paper No./Mail Da 3), 7. ☐ Examiner's Amend	ite
Paper No./Mail Date <u>12/06/2005</u> 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. ⊠ Examiner's Statem 9. □ Other	ent of Reasons for Allowance
		ANGEL CASTRO

U.S. Patent and Trademark Office PTOL-37 (Rev. 7-05) PRIMARY EXAMINER

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DETAILED ACTION

Response to Amendment

1. Applicant's request for reconsideration of the finality of the rejection of the last Office action is persuasive and, therefore, the finality of that action is withdrawn.

2. The reply filed 11/22/2005 was applied to the following effect: All relevant objections and rejections are withdrawn as being satisfied.

Information Disclosure Statement

3. The information disclosure statement (IDS) submitted on 12/06/2005 is in compliance with the provisions of 37 CFR 1.97. Accordingly, the examiner has considered the information disclosure statement.

Reasons for Allowance

4. Claims 1-14 are allowed.

The following is an examiner's statement of reasons for allowance:

This application is for a MAGNETORESISTIVE EFFECT THIN-FILM MAGNETIC HEAD AND MANUFACTURING METHOD OF MAGNETORESISTIVE EFFECT THIN-FILM MAGNETIC HEAD .

• Claim 1 specifies a magnetoresistive effect thin film magnetic head, which requires:

"an additional insulation layer formed so that a distance between said lower shield layer and said upper gap layer increases at a location where said magnetoresistive effect multilayer is absent."

The prior art of record fails to fairly, teach, show or suggest, by either anticipating or rendering obvious, the invention as set forth in the claims of the instant application. Furthermore,

a search made does not detect the combined claimed elements as set forth in the pending claims. Additionally, the reasons for allowance of the claims over the prior art of record is believed to be readily clear, self evident and apparent from the claim language set forth in each of claim 1 when compared and contrasted with the prior art.

More particularly, the instant invention (as set forth in claim 1) provides an additional insulation layer formed so that a distance between said lower shield layer and said upper gap layer increases at a location where said magnetoresistive effect multilayer is absent. None of the cited prior art of record, however, do not disclose such a magnetoresistive effect thin film magnetic head, as set forth in the manner, function and relationship relative to other claimed structures as prescribed by the independent claims.

• Claim 6 specifies a manufacturing method of a magnetoresistive effect thin film magnetic head, which requires:

"forming an additional insulation layer in said recess; and "forming and insulation gap layer of an insulation material at least on said additional insulation layer to surround said lower gap layer and said magnetoresistive effect multilayer;"

The prior art of record fails to fairly, teach, show or suggest, by either anticipating or rendering obvious, the invention as set forth in the claims of the instant application. Furthermore, a search made does not detect the combined claimed elements as set forth in the pending claims. Additionally, the reasons for allowance of the claims over the prior art of record is believed to be readily clear, self evident and apparent from the claim language set forth in each of claim 6 when compared and contrasted with the prior art.

More particularly, the instant invention (as set forth in claim 6) provides forming an additional insulation layer in said recess; and forming and insulation gap layer of an insulation material at least on said additional insulation layer to surround said lower gap layer and said magnetoresistive effect multilayer. None of the cited prior art of record, however, do not disclose such a magnetoresistive effect thin film magnetic head, as set forth in the manner, function and relationship relative to other claimed structures as prescribed by the independent claims.

• Claim 9 specifies a manufacturing method of a magnetoresistive effect thin film magnetic head, which requires:

"forming insulation gap layer of an insulation material on said lower shield layer to surround said lower gap layer and said magnetoresistive effect multilayer;" and "forming an additional insulation layer on said insulation gap layer at a position where said magnetoresistive effect multilayer is absent."

The prior art of record fails to fairly, teach, show or suggest, by either anticipating or rendering obvious, the invention as set forth in the claims of the instant application. Furthermore, a search made does not detect the combined claimed elements as set forth in the pending claims. Additionally, the reasons for allowance of the claims over the prior art of record is believed to be readily clear, self evident and apparent from the claim language set forth in each of claim 9 when compared and contrasted with the prior art.

More particularly, the instant invention (as set forth in claim 9) provides forming insulation gap layer of an insulation material on said lower shield layer to surround said lower gap layer and said magnetoresistive effect multilayer and forming an additional insulation layer on said insulation gap layer at a position where said magnetoresistive effect multilayer is absent.

None of the cited prior art of record, however, do not disclose such a magnetoresistive effect thin film magnetic head, as set forth in the manner, function and relationship relative to other claimed structures as prescribed by the independent claims.

• Claim 12 specifies a manufacturing method of a magnetoresistive effect thin film magnetic head, which requires:

"forming a recess in a part of lower shield layer at a position where said magnetoresistive effect multilayer is to be absent;" "forming a first additional insulation layer in said recess;" and "forming a second additional insulation layer on said insulation gap layer at a position where said magnetoresistive effect multilayer is absent;"

The prior art of record fails to fairly, teach, show or suggest, by either anticipating or rendering obvious, the invention as set forth in the claims of the instant application. Furthermore, a search made does not detect the combined claimed elements as set forth in the pending claims. Additionally, the reasons for allowance of the claims over the prior art of record is believed to be readily clear, self evident and apparent from the claim language set forth in each of claim 12 when compared and contrasted with the prior art.

More particularly, the instant invention (as set forth in claim 12) provides forming a recess in a part of lower shield layer at a position where said magnetoresistive effect multilayer is to be absent; forming a first additional insulation layer in said recess and forming a second additional insulation layer on said insulation gap layer at a position where said magnetoresistive effect multilayer is absent. None of the cited prior art of record, however, do not disclose such a magnetoresistive effect thin film magnetic head, as set forth in the manner, function and relationship relative to other claimed structures as prescribed by the independent claims.

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5. Any comments considered necessary by applicant must be submitted no later than the

payment of the issue fee and, to avoid processing delays, should preferably accompany the issue

fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for

Allowance."

Conclusion

6. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Christopher R. Magee whose telephone number is (571) 272-

7592. The examiner can normally be reached on M-F, 8: 00 am-5: 30 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, William Korzuch can be reached on (571) 272-7589. The fax phone number for the

organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about the PAIR

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR

system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Christopher R. Magee Patent Examiner

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December 20, 2005

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